

IN THE U.S. PATENT AND TRADEMARK OFFICE

In re application of

Koichi NANIWAE

Conf. 9283

Application No. 10/573,492

Group 2892

Filed May 15, 2006

Examiner E. Jones

METHOD OF CLEANING TREATMENT AND METHOD FOR MANUFACTURING
SEMICONDUCTOR DEVICE

AMENDMENT

Assistant Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

November 23, 2009

Sir:

In response to the Official Action of August 24, 2009,
please amend the above-identified application as follows:

Amendments to the Claims are reflected in the listing of
claims, which begins on page 2 of this paper.

Remarks begin on page 12 of this paper.